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PATENT APPLICATION

10200 MAIL ROOM

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Toshiro HAYAKAWA, et al.

Application No. 09/315,068

Group Art Unit: 2828

Confirmation No.: 5982

Examiner: Jeffrey N. Zahn

Filed: May 20, 1999

#14/84t.

Marsha
4/4/02

For: SEMICONDUCTOR LASER AND METHOD OF MANUFACTURING THE SAME

PETITION FOR EXTENSION OF TIME UNDER 37 C.F.R. § 1.136

Commissioner for Patents
Washington, D.C. 20231

Sir:

Pursuant to 37 C.F.R. § 1.136, Applicant hereby petitions for an extension of time of two month(s), extending the time for responding to the Office Action of November 1, 2001 to April 1, 2002.

A check for the statutory fee of \$400.00 is attached. Please charge any additional fees under 37 C.F.R. § 1.16 or § 1.17 necessary to keep this application pending in the Patent and Trademark Office or credit any overpayment to Deposit Account No. 19-4880. A duplicate copy of this sheet is enclosed.

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400.00 OP

Respectfully submitted,

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